

# *Nanoscale single quantum dot devices at 1300 nm*

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**Quantum Devices group at EPFL:**

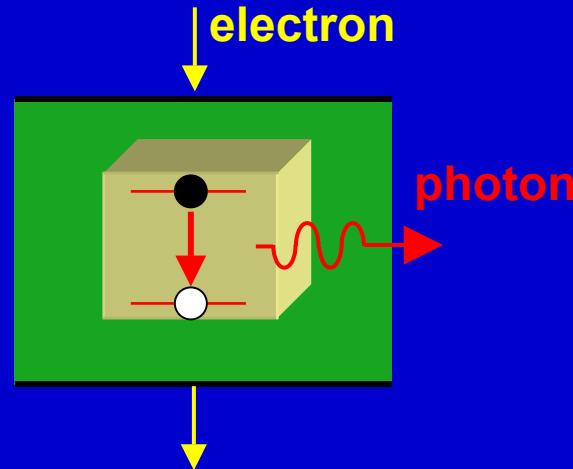
**Postdocs: L.H. Li, C. Monat, V. Zwiller (now at ETHZ)**

**PhD students: B. Alloing, C. Zinoni**

**Undergrads: G. Buchs, M. Gobet (now at Texas Univ.)**

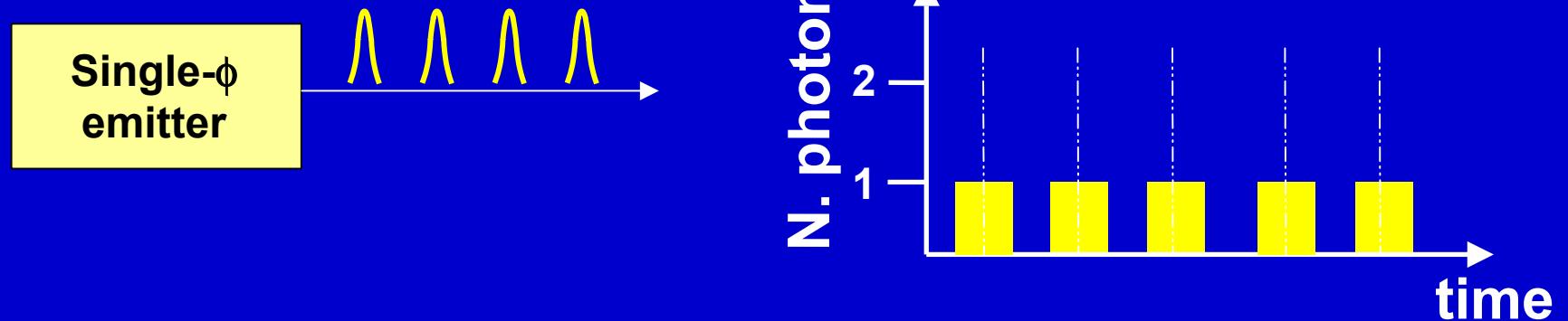
**Funding: Swiss National Science Foundation**

# Outline

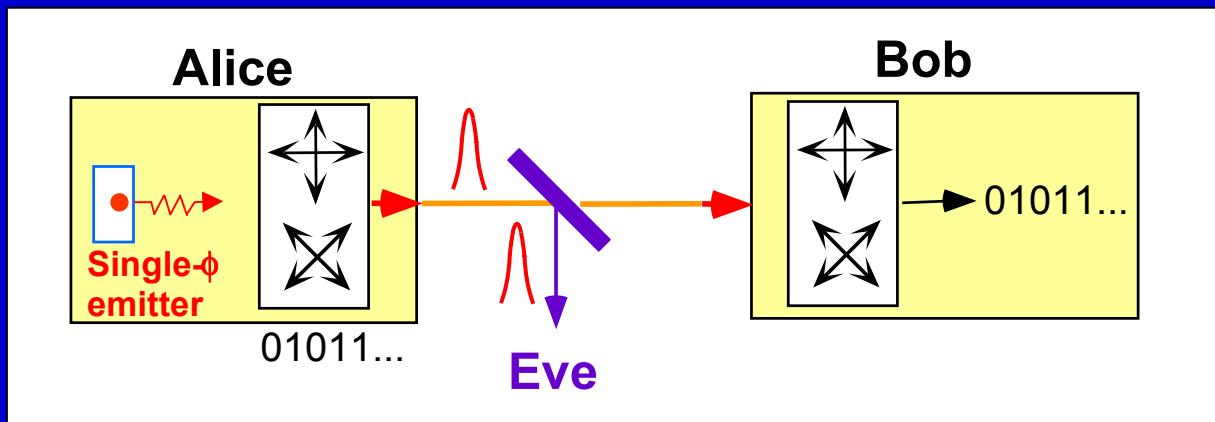


- Single-photon emitters
- Practical issues for single-photon emitters:
  - ◆ Wavelength & density: Growth of QDs at 1300 nm
  - ◆ Electrical injection: Nanosized QD LEDs
  - ◆ Controlling the optical density of states
- Conclusions

# Single photon emitters



## Application: Quantum cryptography



**BB84**  
quantum key  
distribution



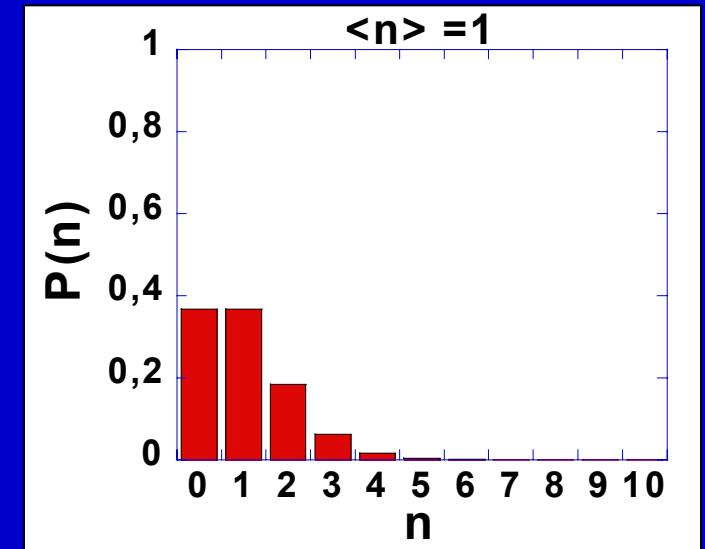
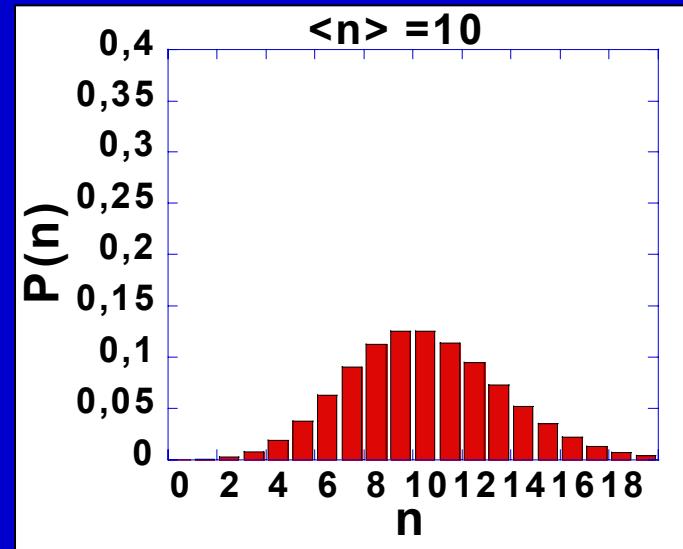
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# A close look at single photons



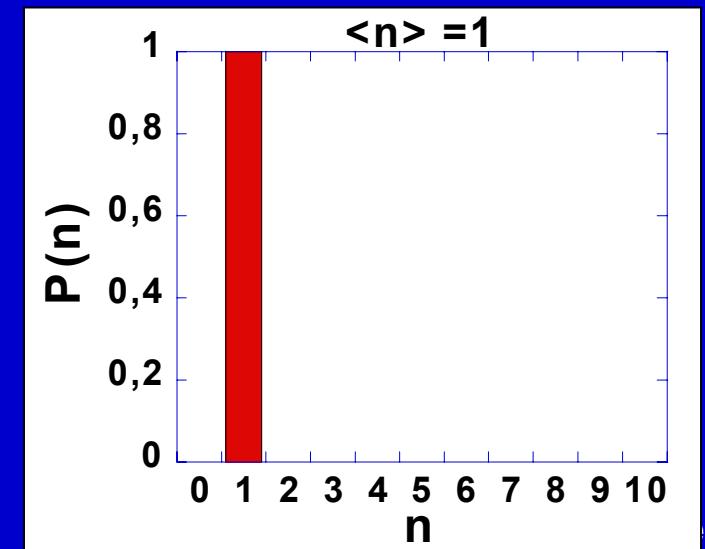
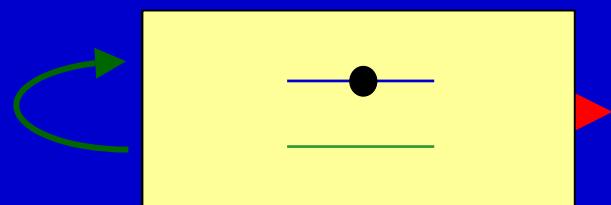
"Classical" light sources (e.g. a laser) are Poissonian:

$$\sigma_n^2 = \langle n \rangle$$



"Nonclassical" light source:

*Single quantum system:*



# The quest for single- $\phi$ sources



## The simplest single- $\phi$ sources:

- Single atoms
- Single ions
- Single molecules
- ...

## Wish list for single- $\phi$ sources:

- Compact, electrically pumped
- Efficient
- Emitting at 1300-1550 nm

⇒ A semiconductor LED!

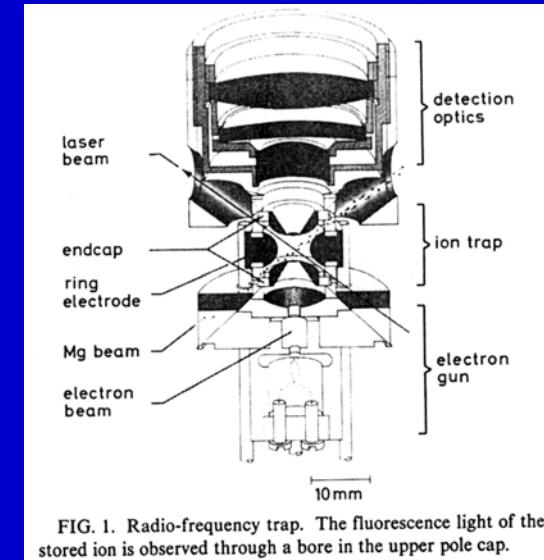
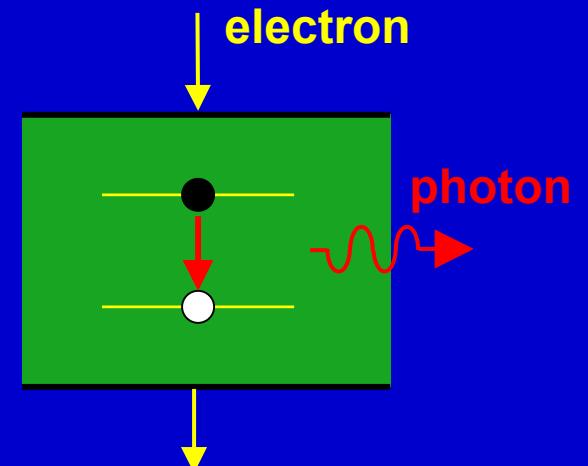


FIG. 1. Radio-frequency trap. The fluorescence light of the stored ion is observed through a bore in the upper pole cap.

(Diedrich and Walther, PRL 1987)

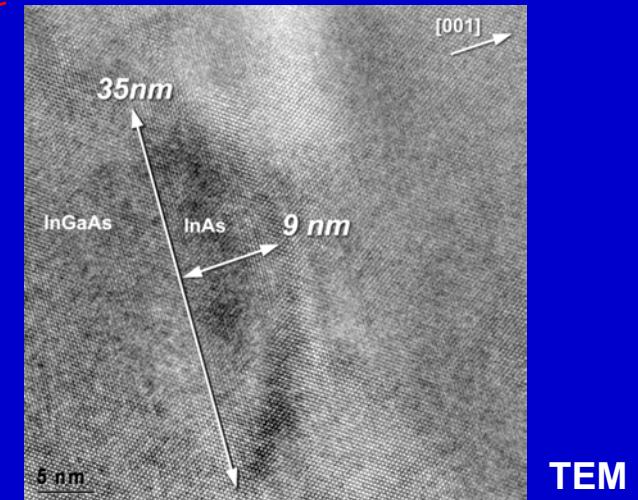
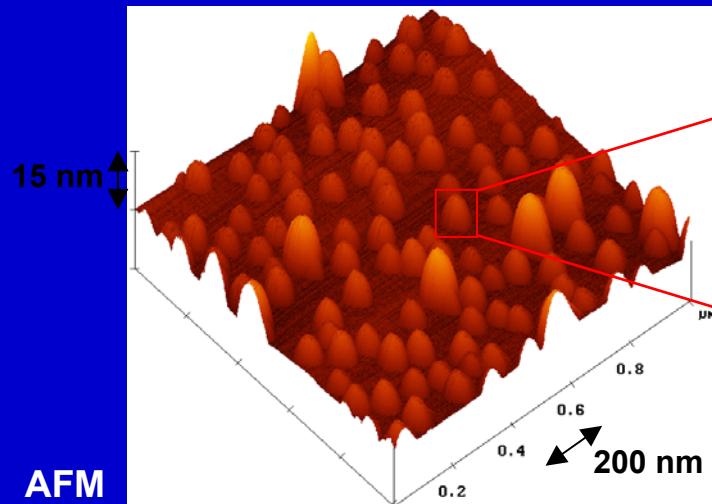


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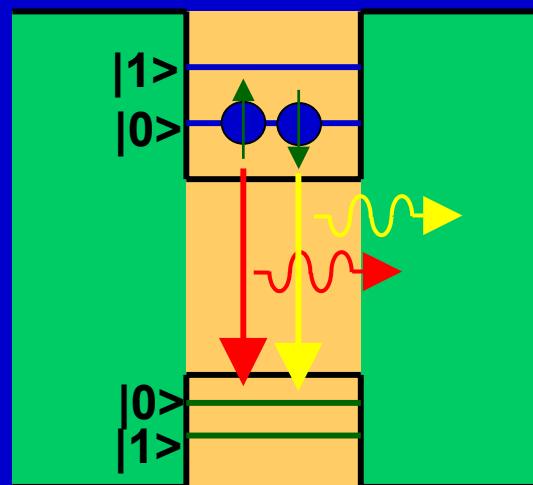
# Semiconductor Quantum Dots



MBE growth of InAs on GaAs:

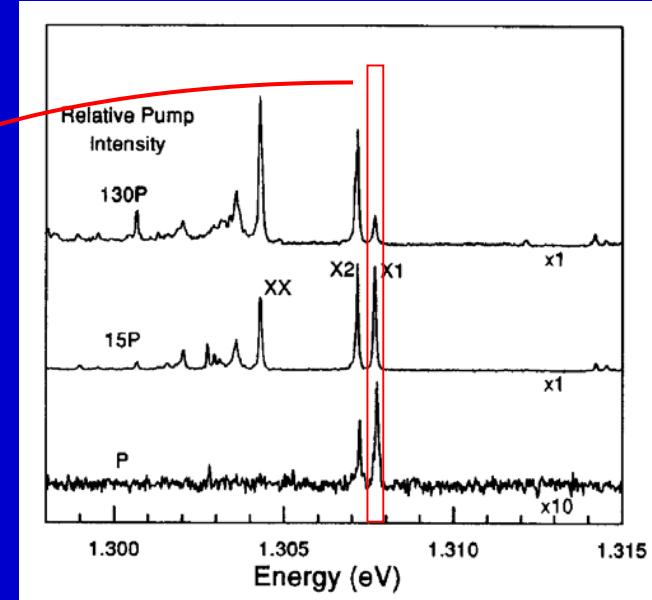


GaAs InAs GaAs

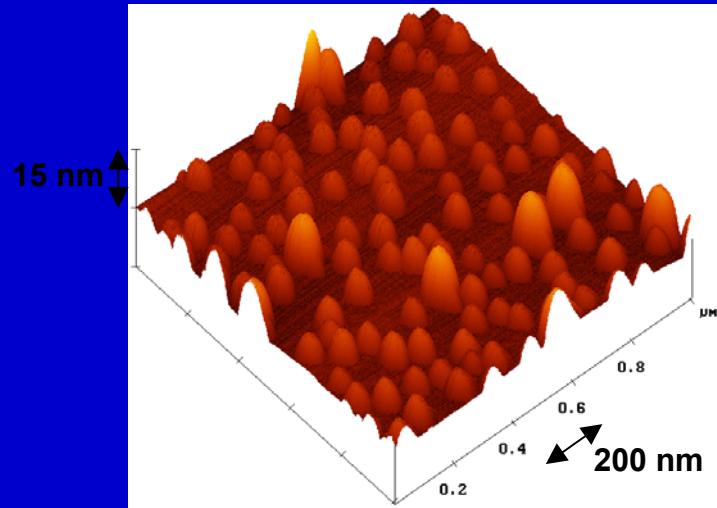


Single-photon  
emission

(Kiraz et al., PRB 2002)



# Isolating single QDs

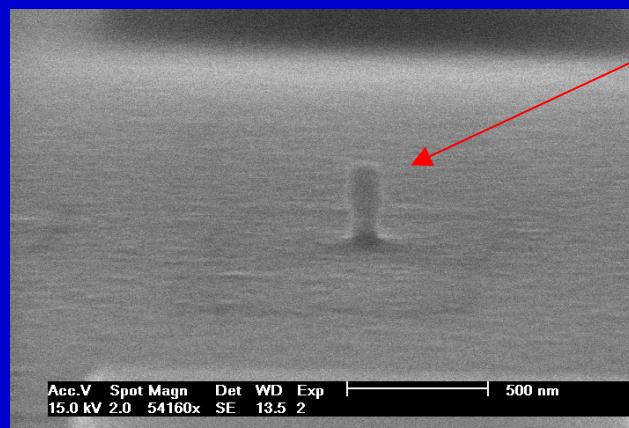


High areal density



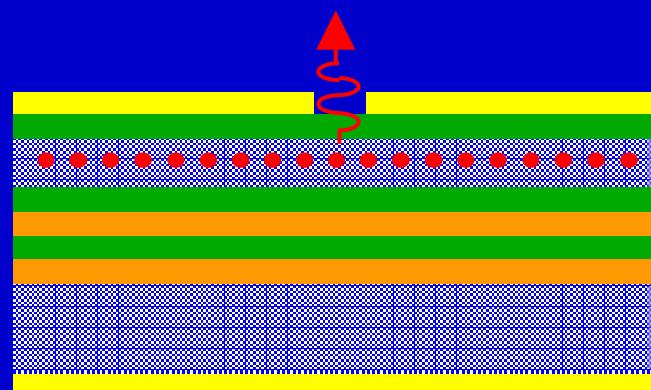
Need very high spatial  
resolution!

Nanomesas:



≈ 100 nm  
≈ 1 QD

Shadow-mask apertures:



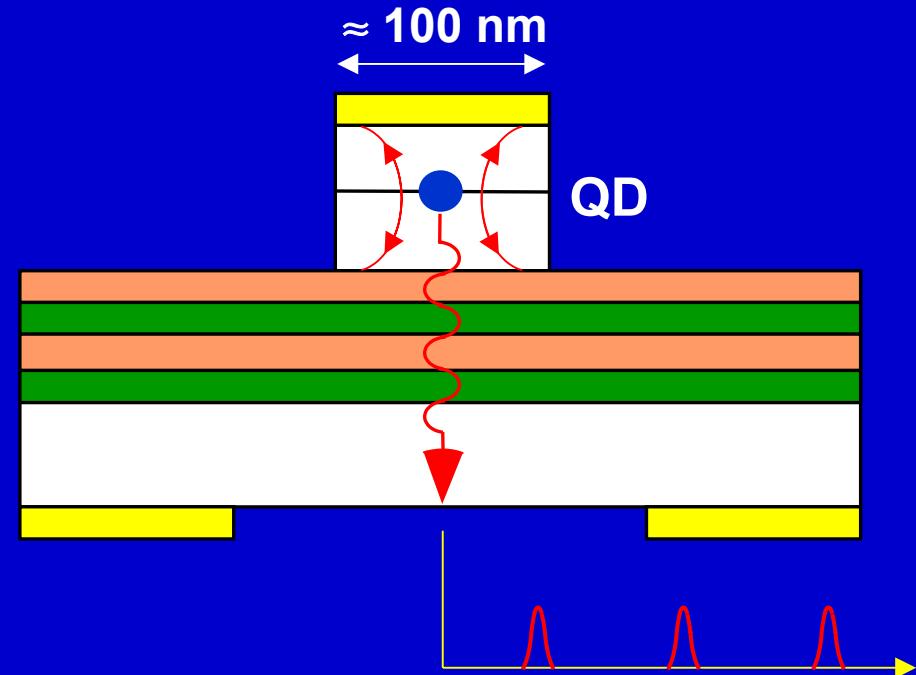
CNR-IFN Roma

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## Single-QD LED ?

- Electrical pumping ?
- Efficiency ?
- Emission at 1300 nm ?



### Our approach:

- Sparse InAs/GaAs QDs at 1300 nm
- Nanostructured LEDs
- Nanocavities for efficient LEDs

# Controlling the density by the coverage



In As



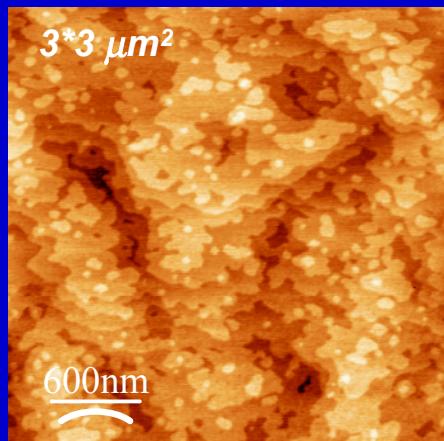
In As



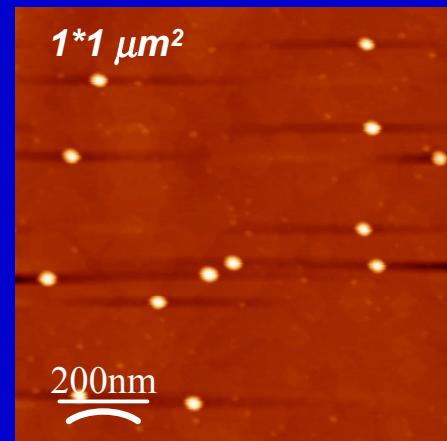
In As



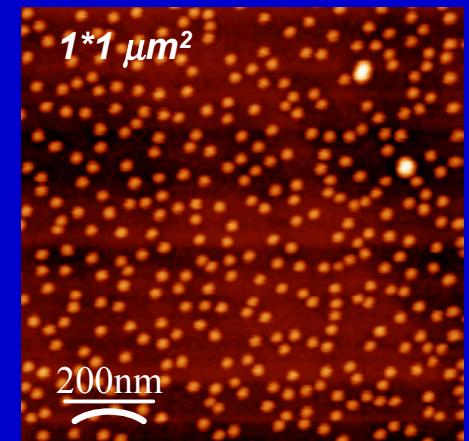
530°C, 0.163 μm/hour:



1.7 MLs < critical thickness  
No QDs, streaky RHEED



1.8 MLs ≈ critical thickness  
15  $\mu\text{m}^{-2}$ , slightly spotty RHEED



3 MLs >> critical thickness  
340  $\mu\text{m}^{-2}$ , spotty RHEED

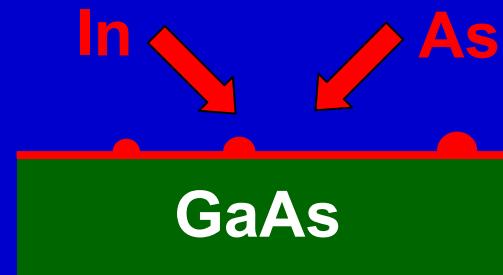


- Low density at low coverage (*Leonard et al., PRB 1994*)
- Wavelength?

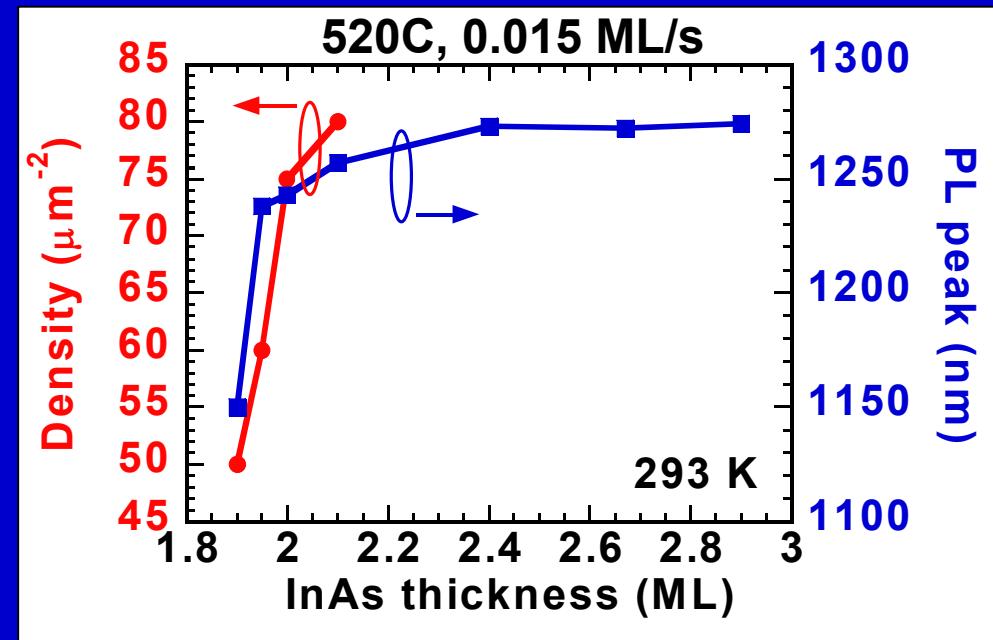
# Low-density QDs



Coverage affects emission wavelength:



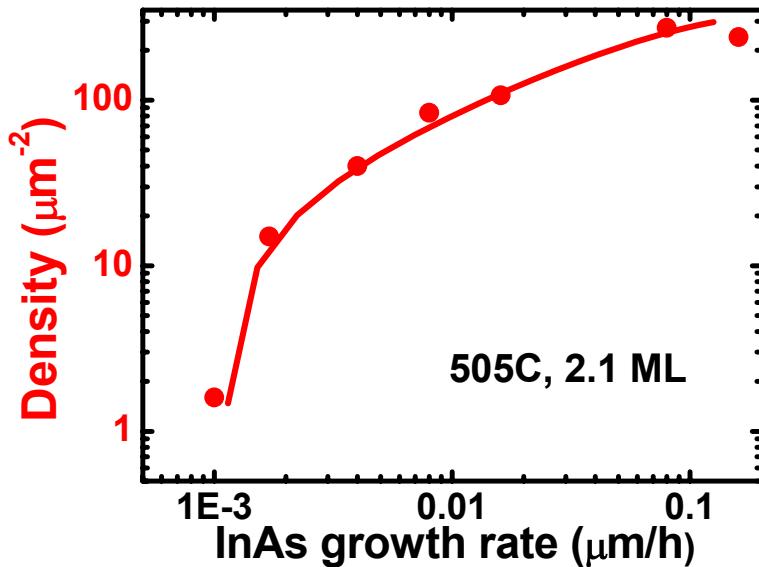
Blue-shift at low coverage  
(smaller QD size, lower In content)



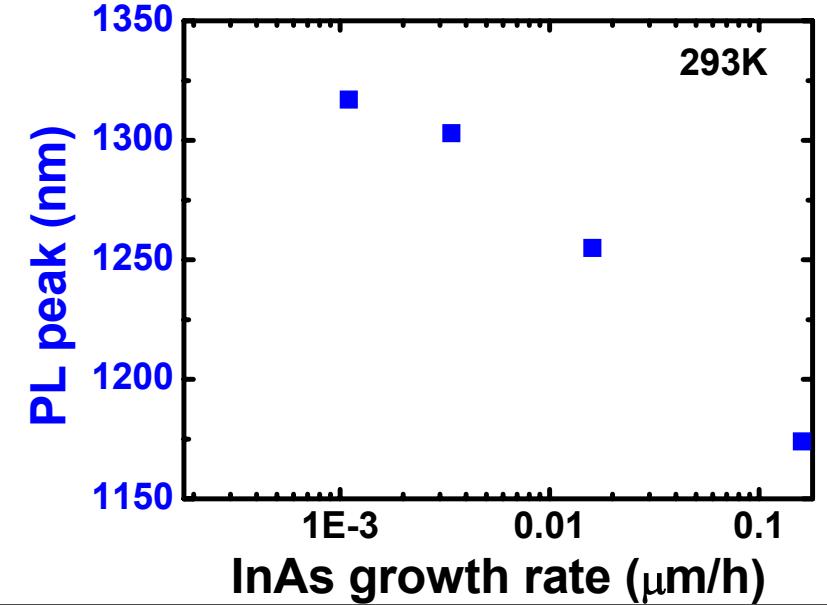
Difficult to grow large and In-rich QDs at small In coverage

Low growth rate  $\Rightarrow$  Increased diffusion length  $\Rightarrow$  Low density

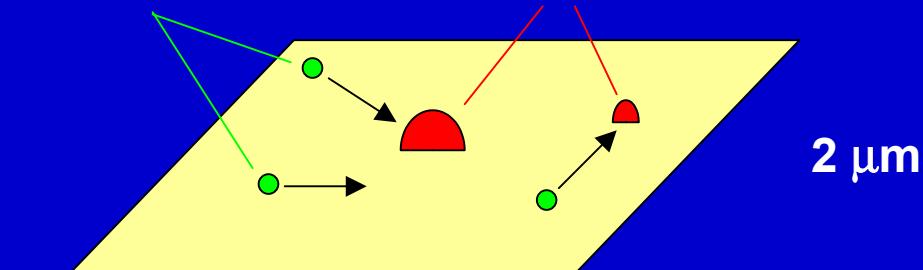
Dots density vs InAs growth rate



Wavelength vs InAs growth rate

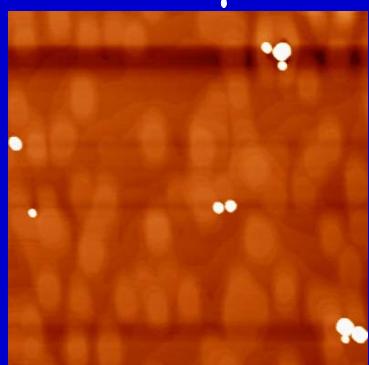


In atoms      InAs islands

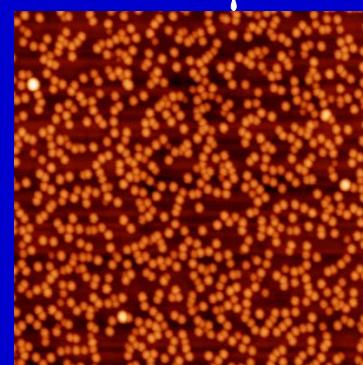


Joyce et al. PRB 2000, Nakata et al. JCG 2000

0.002  $\mu\text{m}/\text{h}$



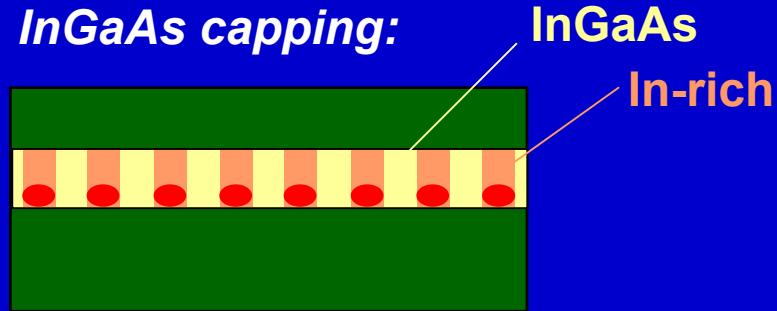
0.015  $\mu\text{m}/\text{h}$



# The role of capping



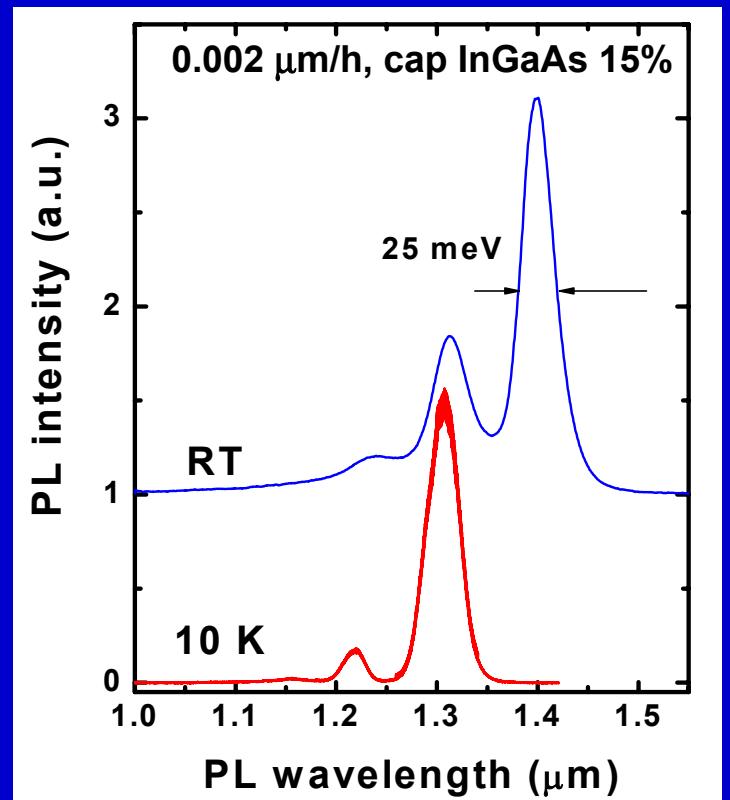
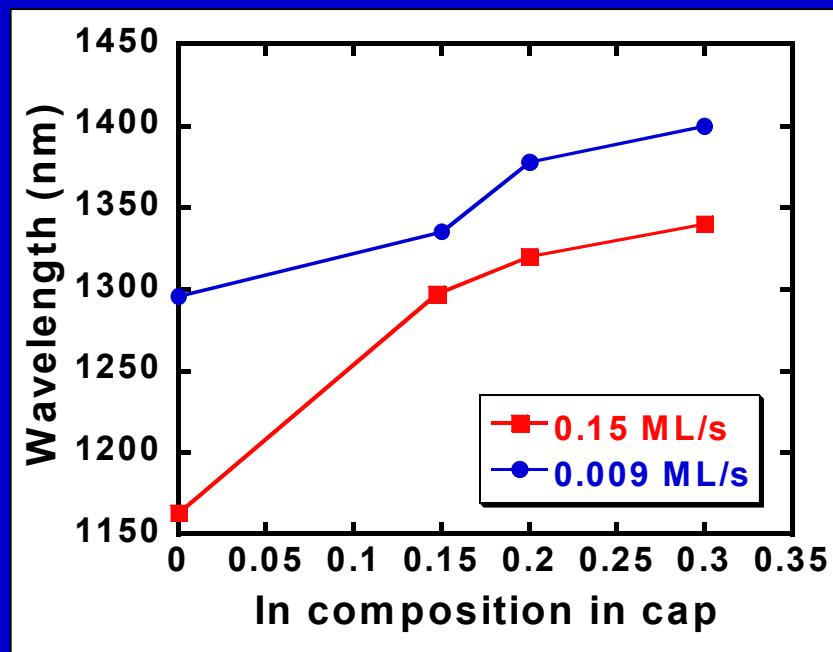
*InGaAs capping:*



*InGaAs capping:*

- Lower strain
- Reduced In segregation

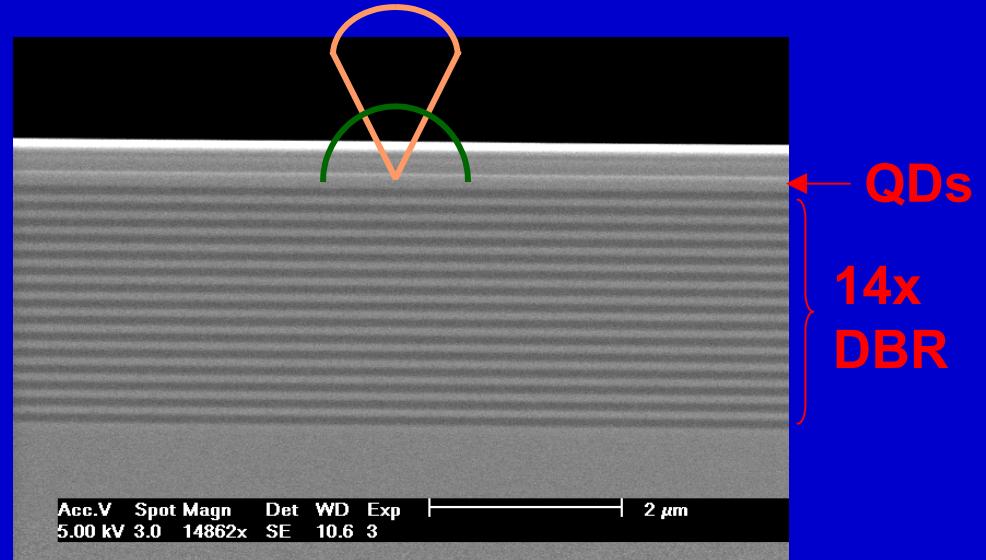
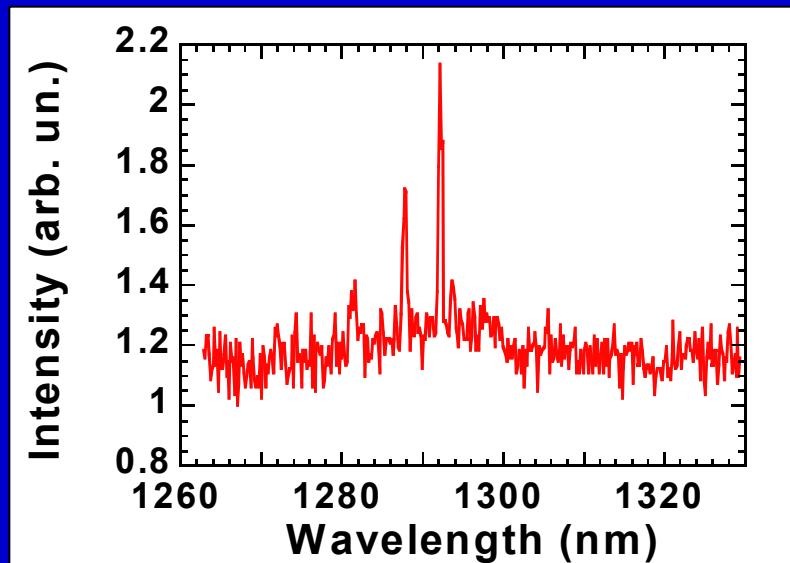
**1300 nm at 5K:**



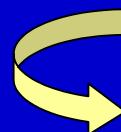
# Single QDs



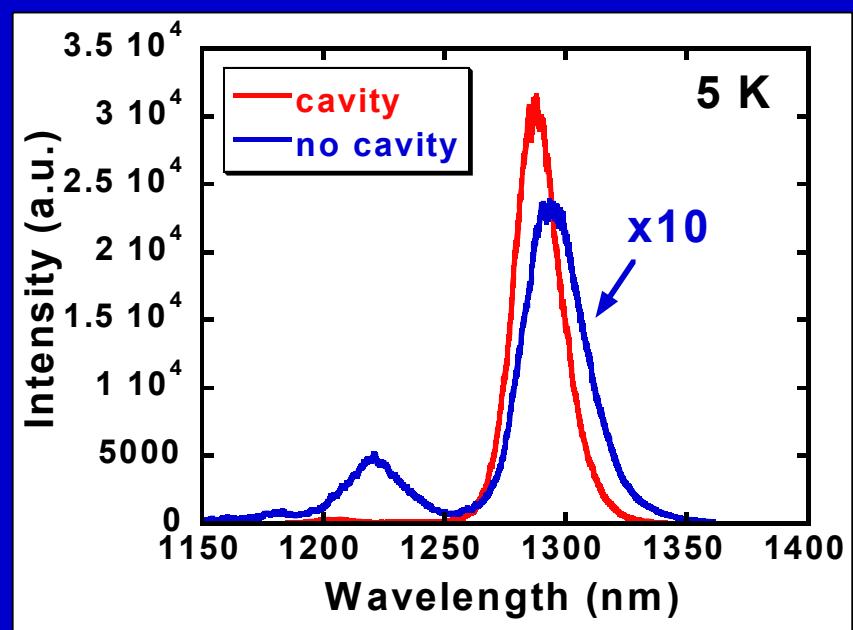
Single QDs in 2  $\mu\text{m}$ -diameter mesa:



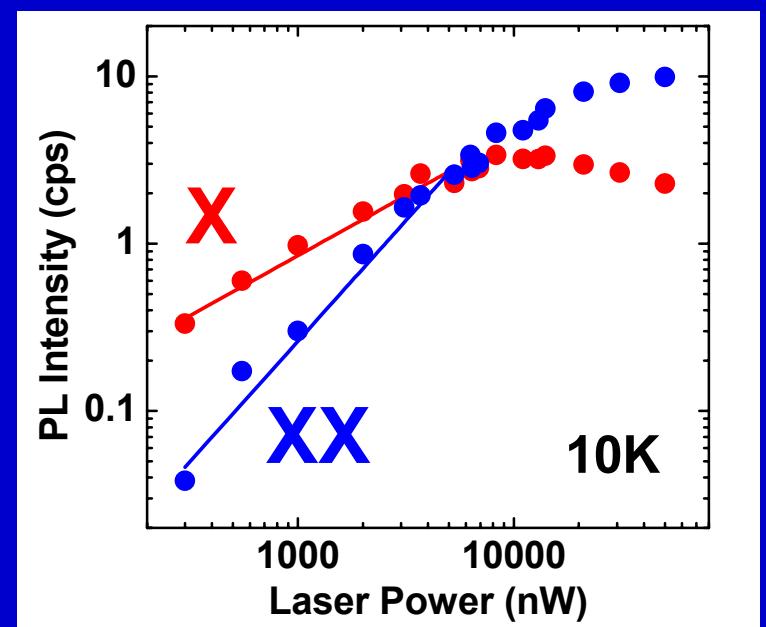
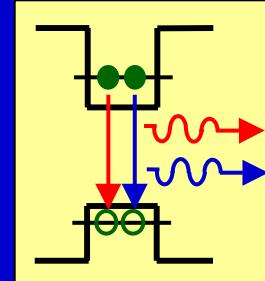
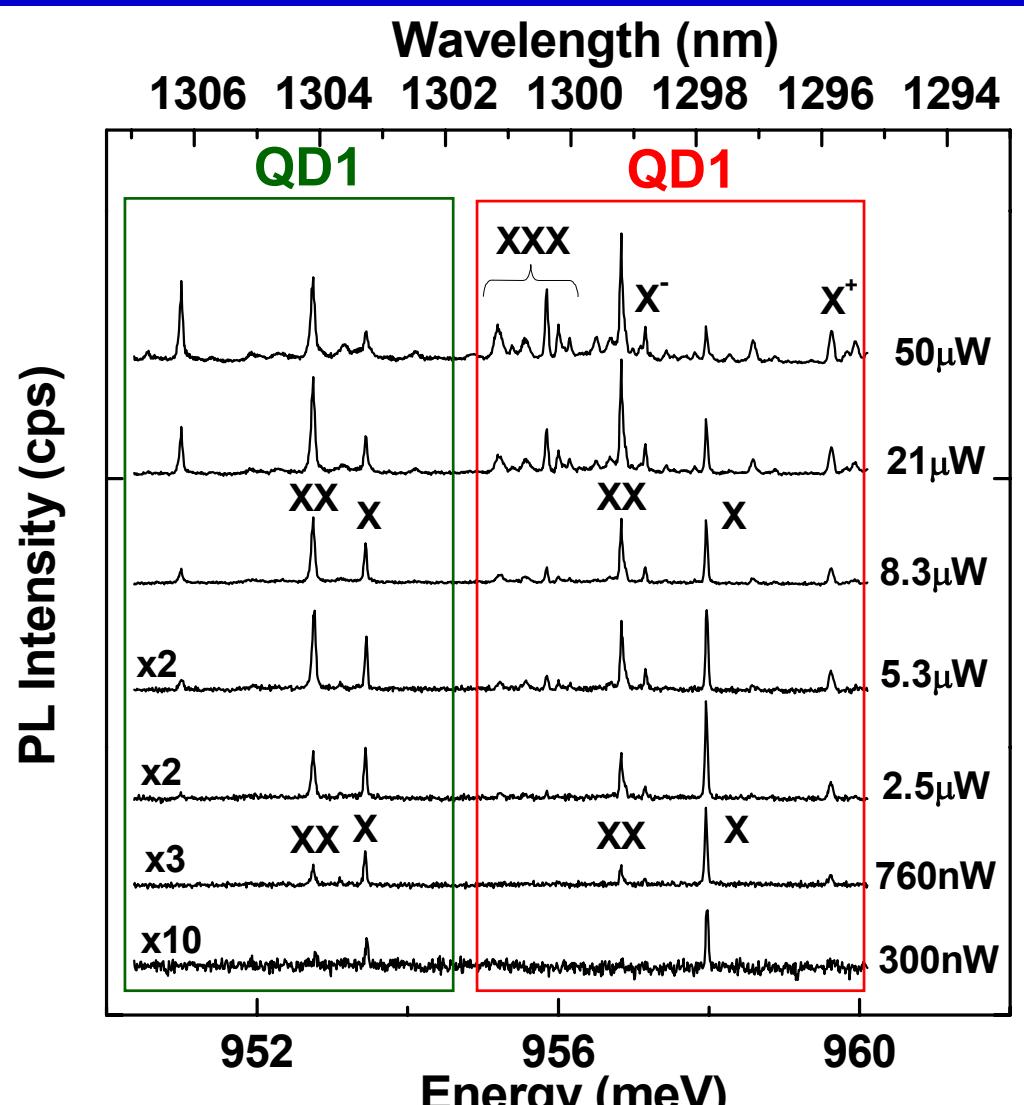
Low signal-to-noise due to noisy InGaAs detector



Increase light extraction with a microcavity



# X-XX spectroscopy at 1300 nm



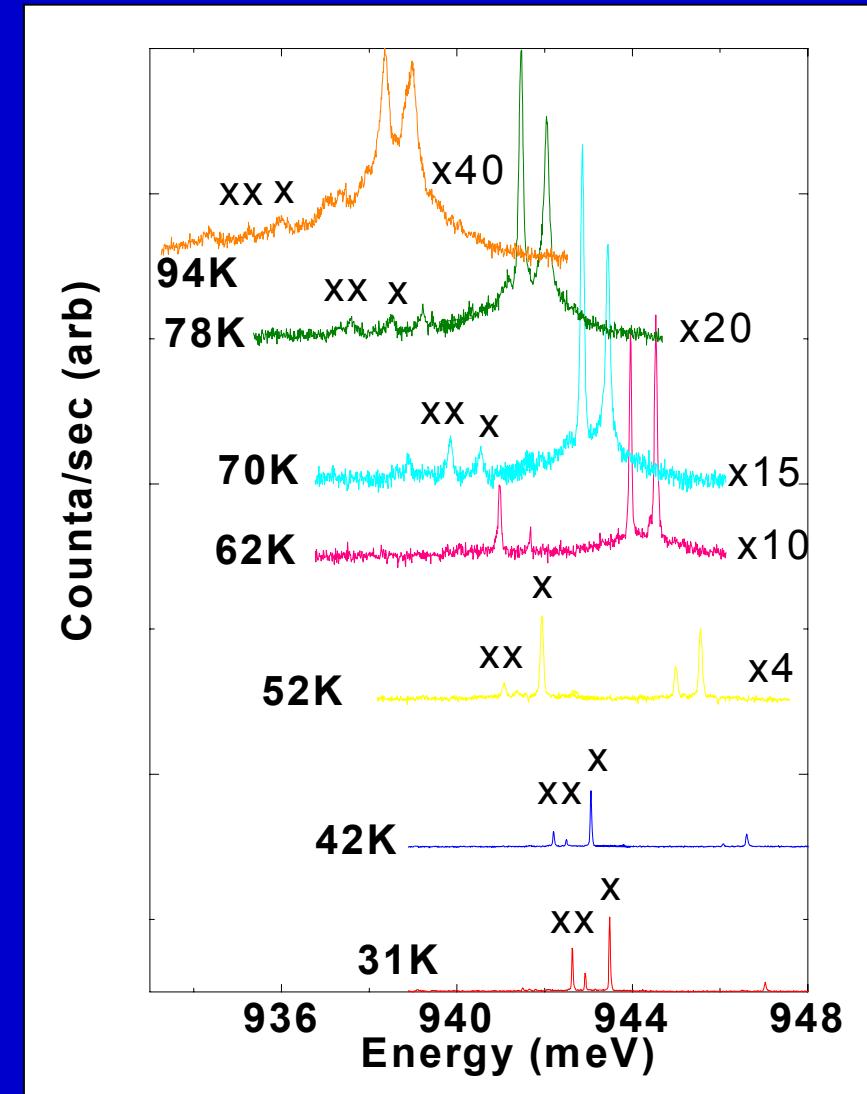
Alloing et al., APL, to be published

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# Temperature dependence



Single QD emission above 77 K:

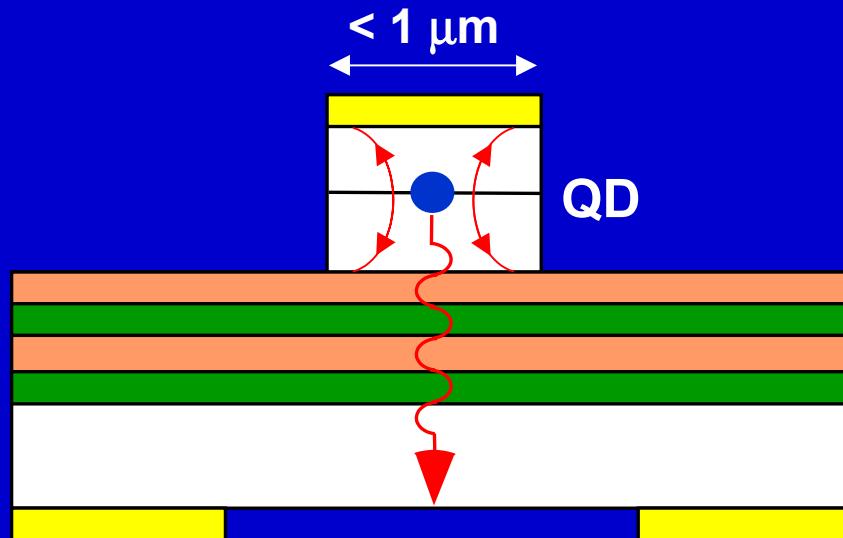


- Population of charged exciton states at high T
- Homogeneous broadening of lines due to phonon scattering
- Single lines can be isolated up to  $T > 77\text{K}$



Towards  $\text{LN}_2$ -cooled single-photon sources at 1300 nm

# Fabrication of nano-LEDs

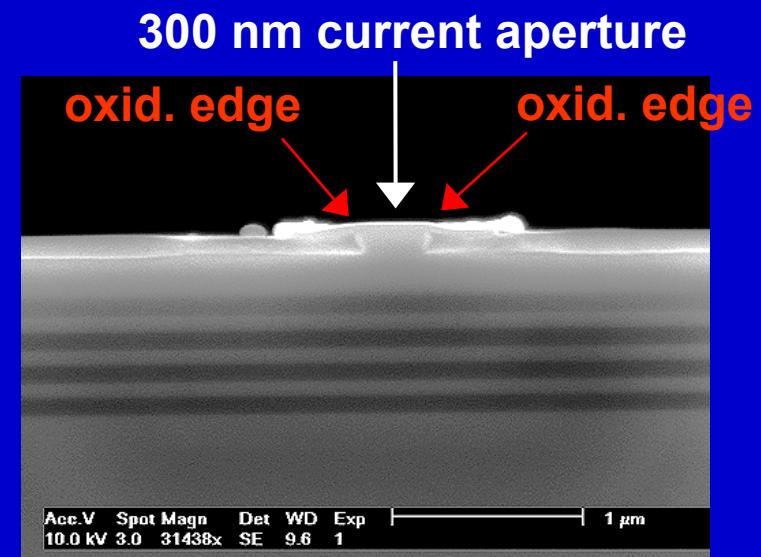
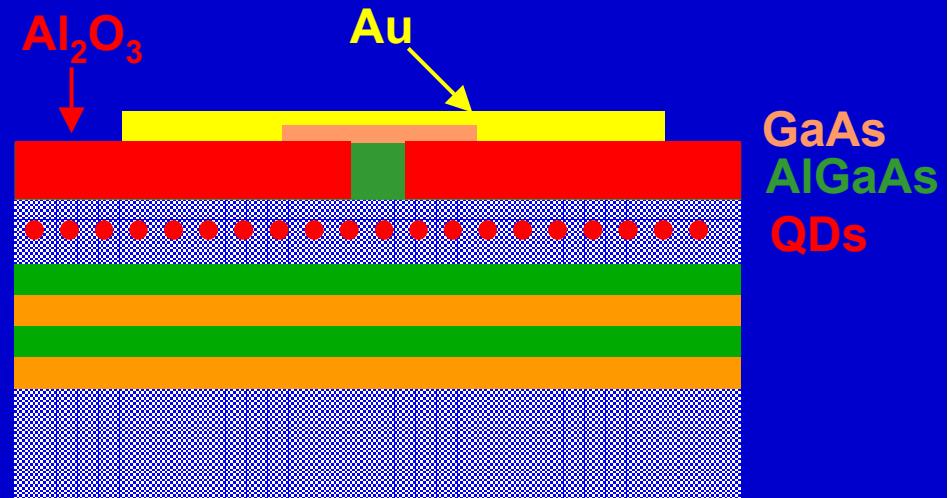


## Etching:

- (⌚) Defects  $\Rightarrow$  NR recombination
- (⌚) Needs high-res. lithography

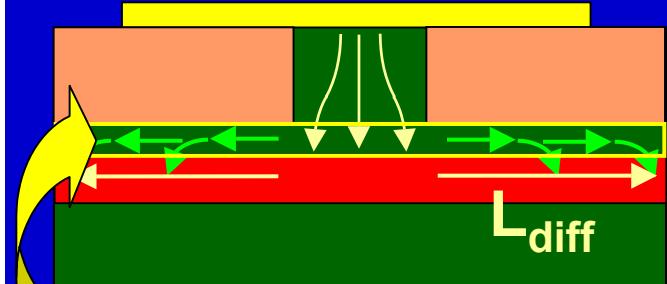
## Oxidation:

- (😊) Does not create defects
- (😊) Smaller dimensions (<100 nm with optical lithography)



Fiore et al., APL 2002

# Confining current injection

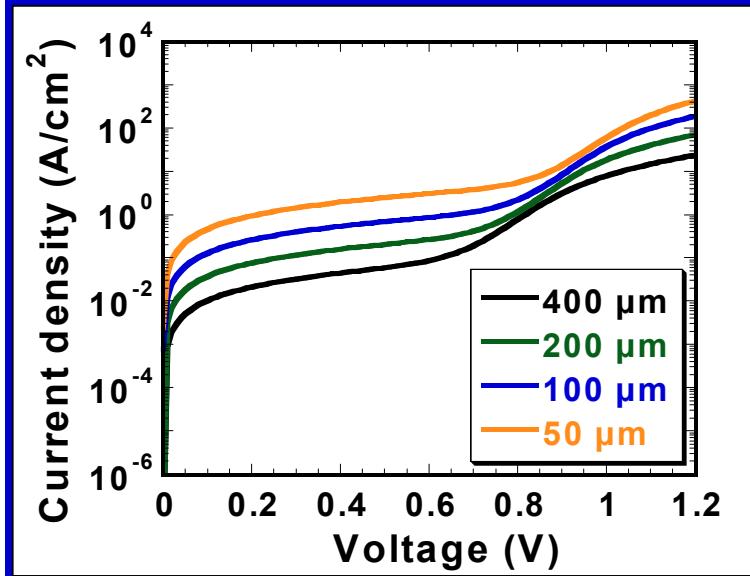


**Current spreading:**  $L_{\text{spread}} = f(R_{//}, R_{\perp})$

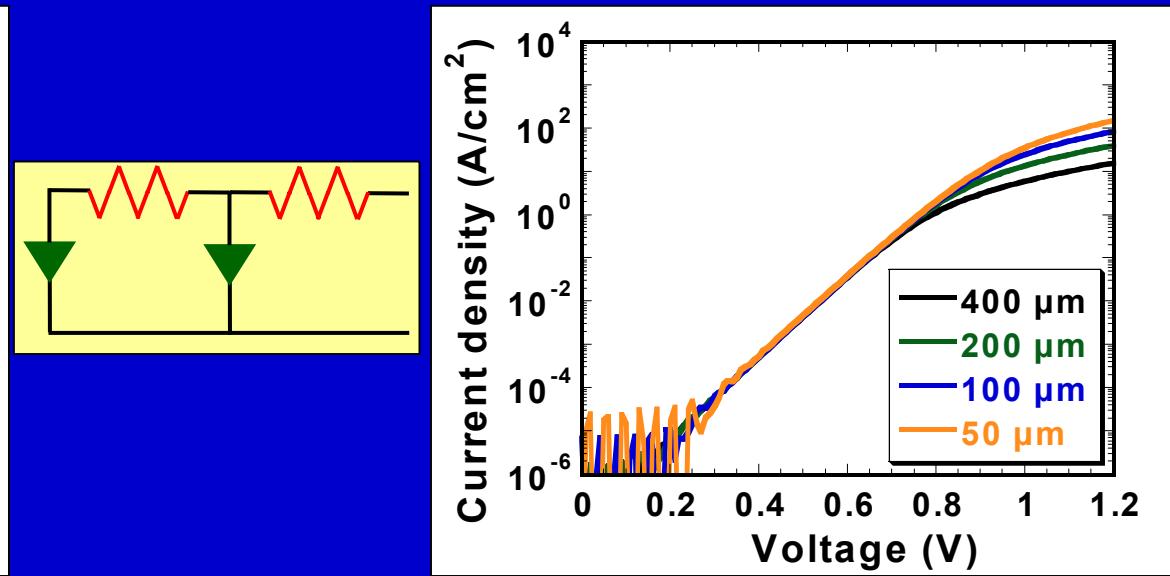
**Carrier diffusion:**  $L_{\text{diff}} = f(\text{material})$

To suppress current spreading: Bandgap engineering of hole injector

doped p-injector:



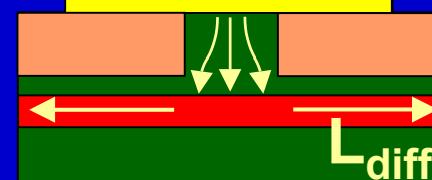
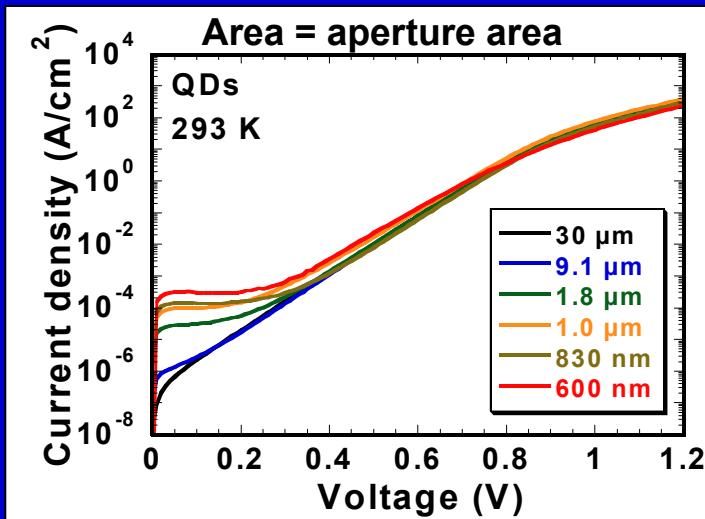
undoped, graded p-injector:



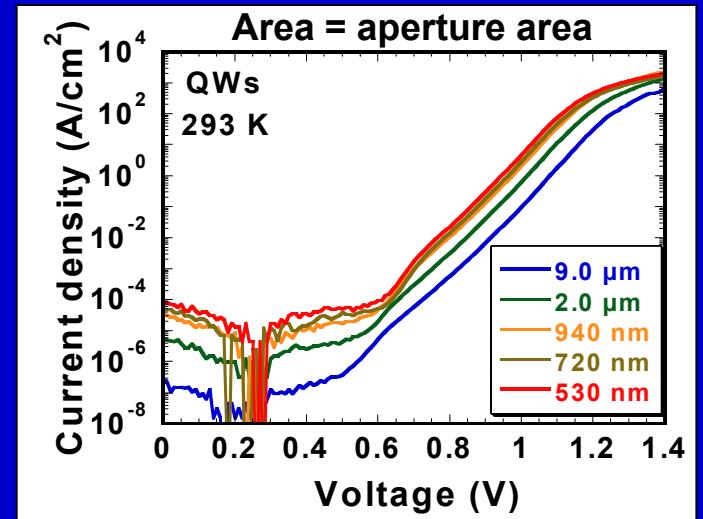
# Ultrasmall LEDs: Scaling



## Quantum dots:

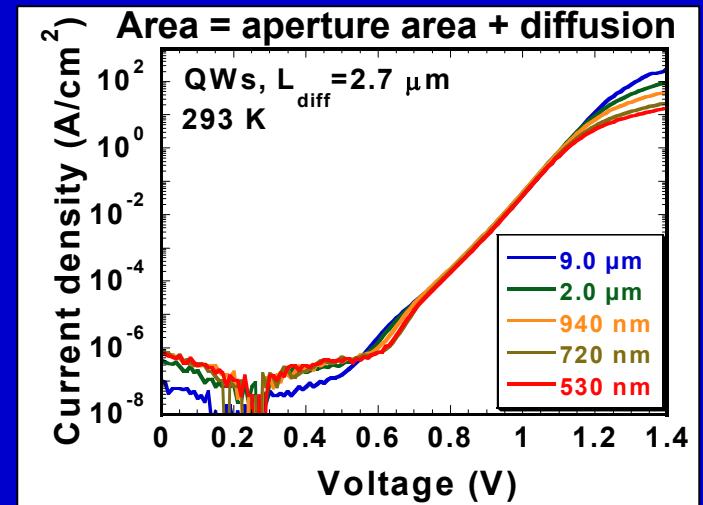
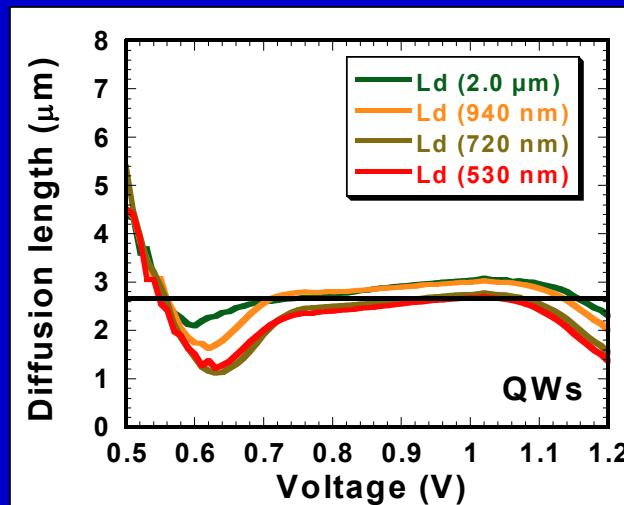


## InGaAs quantum well:

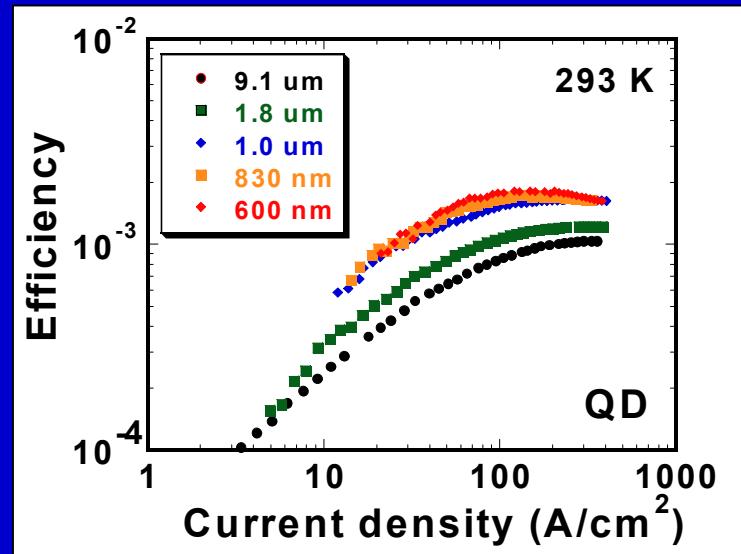


Estimating diff.  
length from IVs:

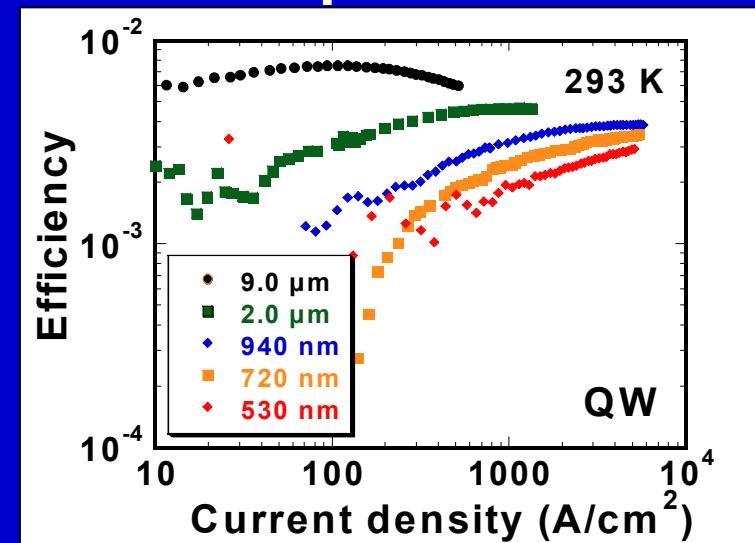
QWs:  $\approx 2.7 \mu\text{m}$   
QDs:  $< 100 \text{ nm}$



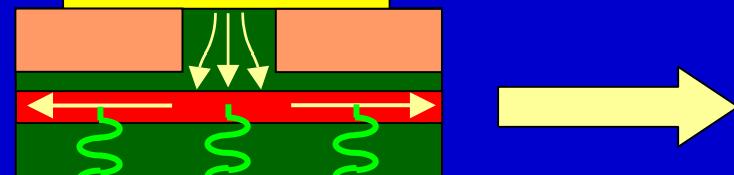
## Quantum dots:



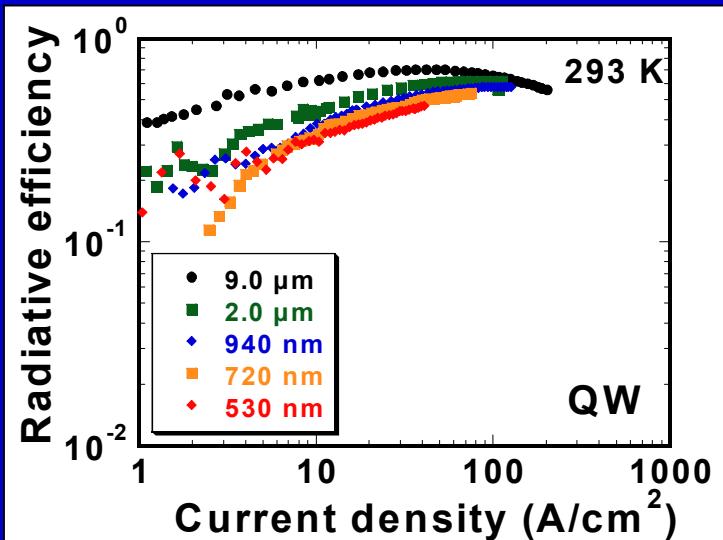
## InGaAs quantum well:



**Carrier diffusion +  
extraction efficiency:**



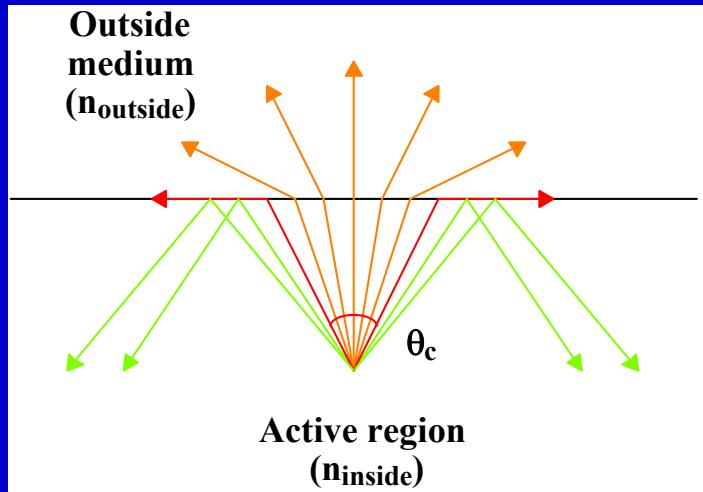
Fiore et al., PRB 2004



# Extracting light from semiconductors



The problem of light extraction:



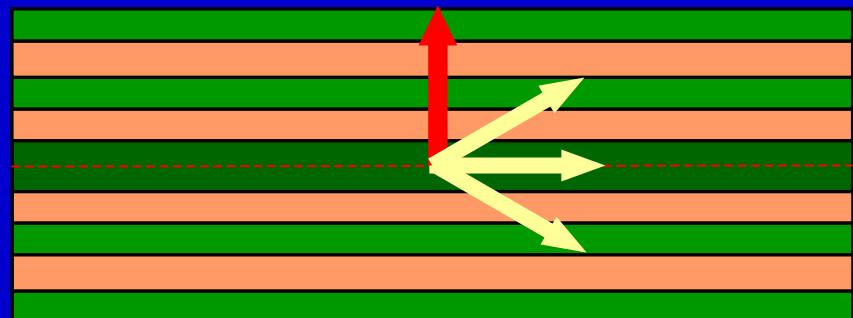
Total internal reflection

$$n(\text{GaAs}) \approx 3.5$$

$$\eta_{\text{extr}} = \frac{\Omega}{4\pi} \approx 2\%$$

Planar  $\mu$ -cavity: no control in lateral directions

$$\Rightarrow \eta_{\text{max}} \approx 20\%$$



Need to change carrier-photon interaction  
so that light is generated only in useful directions Andrea Fiore

# Microcavities & QDs



Spontaneous emission rate:

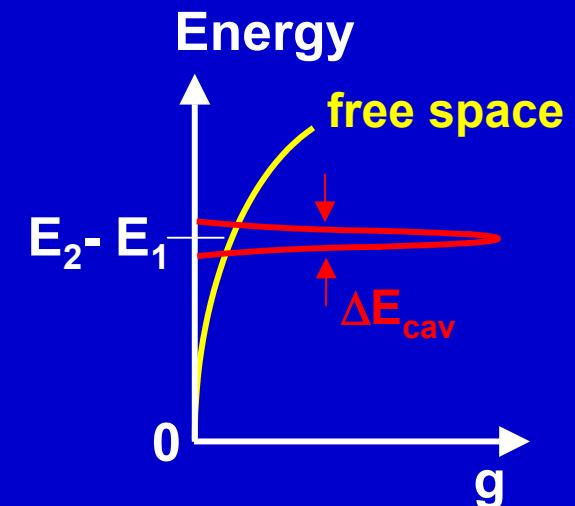
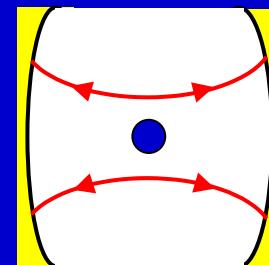
$$W_{if} \propto |r_{12}|^2 \frac{g(E_2 - E_1)}{V}$$

**g(E):** Opt. density of states per unit energy  
**V:** Mode volume

free space:  $g_{FS}(E) = \frac{8\pi E^2}{h^3 c^3} V$

cavity:

$$g_{cav}^{\max} = \frac{1}{\Delta E_{cav}}$$



Sp. em. rate enhancement: (Purcell, 1946)

$$F_P = \frac{W_{cav}}{W_{FS}} \propto \frac{1}{\Delta E_{cav} V} \frac{1}{E^2} \propto Q \frac{\lambda^3}{V}$$

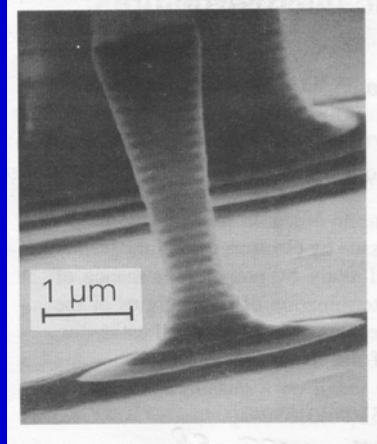
$$F_P \gg 1 \rightarrow \eta \approx 100\%$$

(all photons emitted in cavity mode)

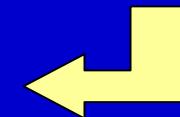
# Electrical injection?



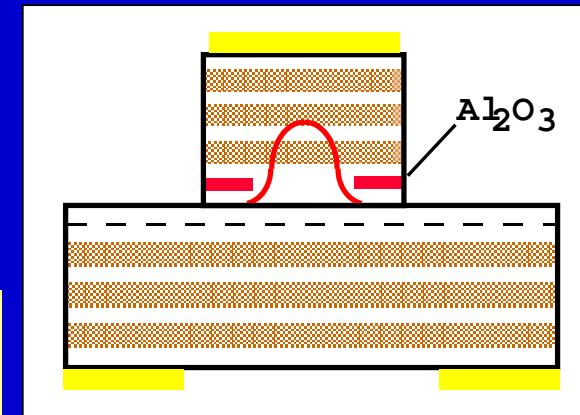
**Micropillars** (Gérard et al., PRL 1998) :



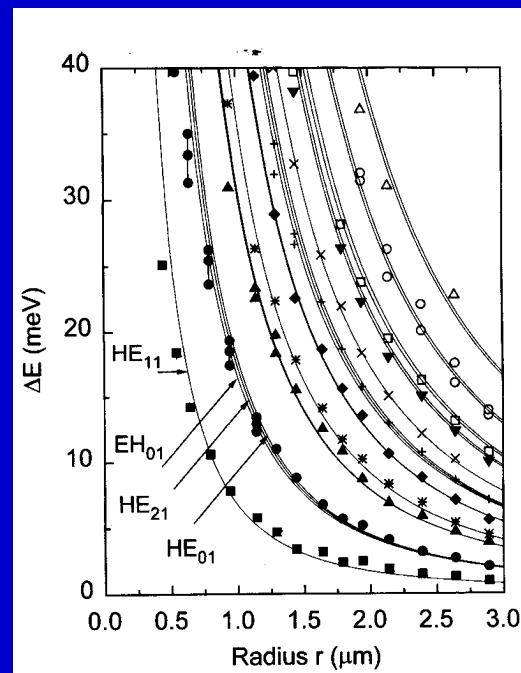
Strong optical confinement,  
optical excitation



**VCSELs:**

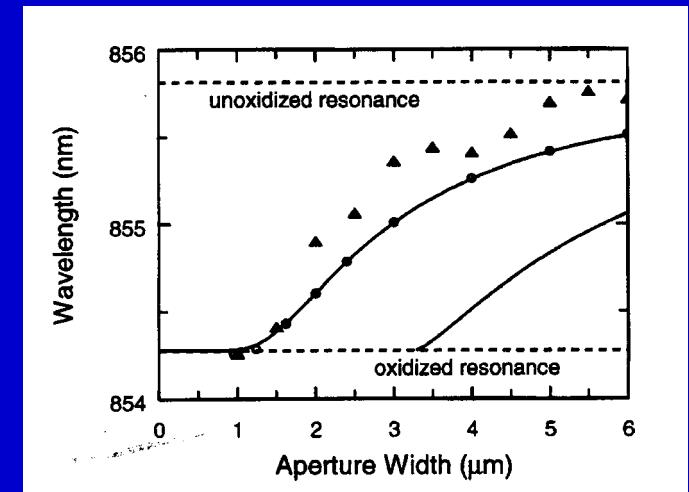


Low optical confinement,  
electrical inj.



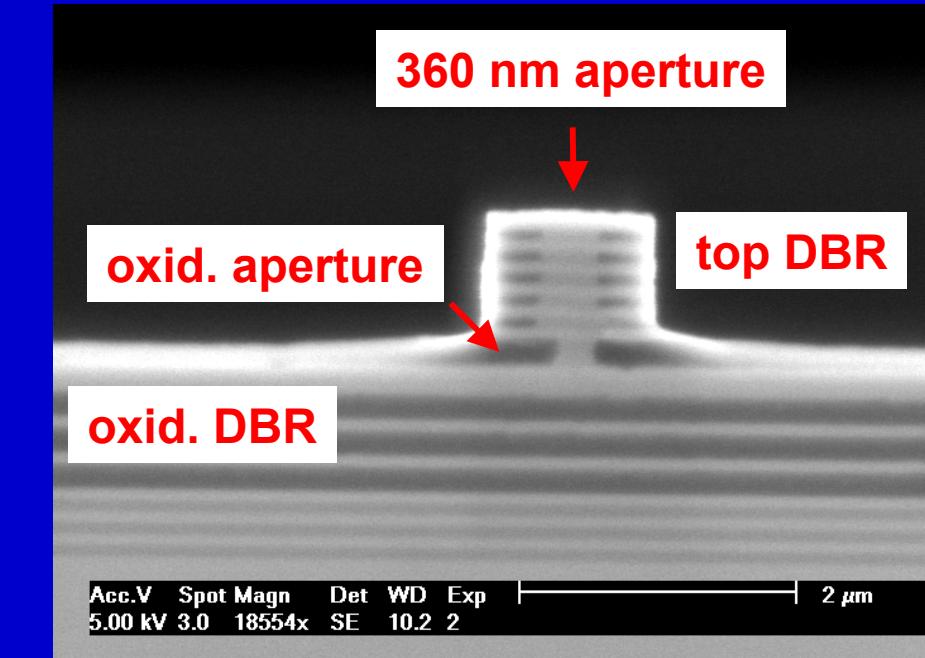
Strong optical confinement,  
and  
electrical injection?

Serkland et al., APL 2000:



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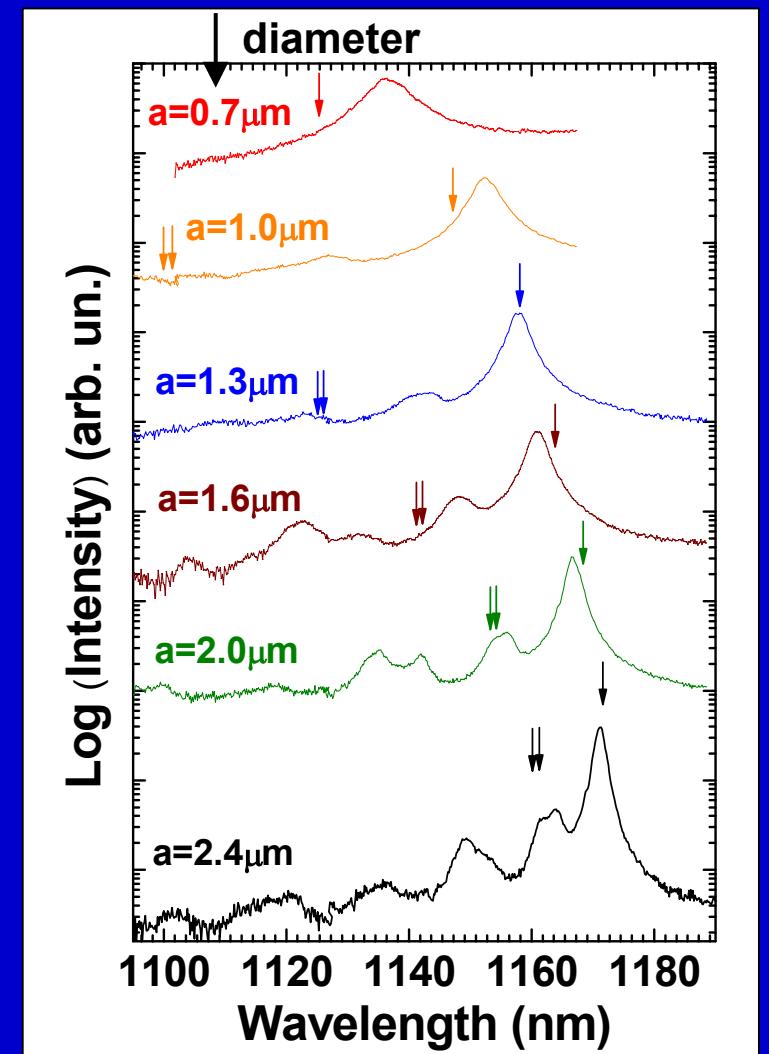
# 3D microcavity LED



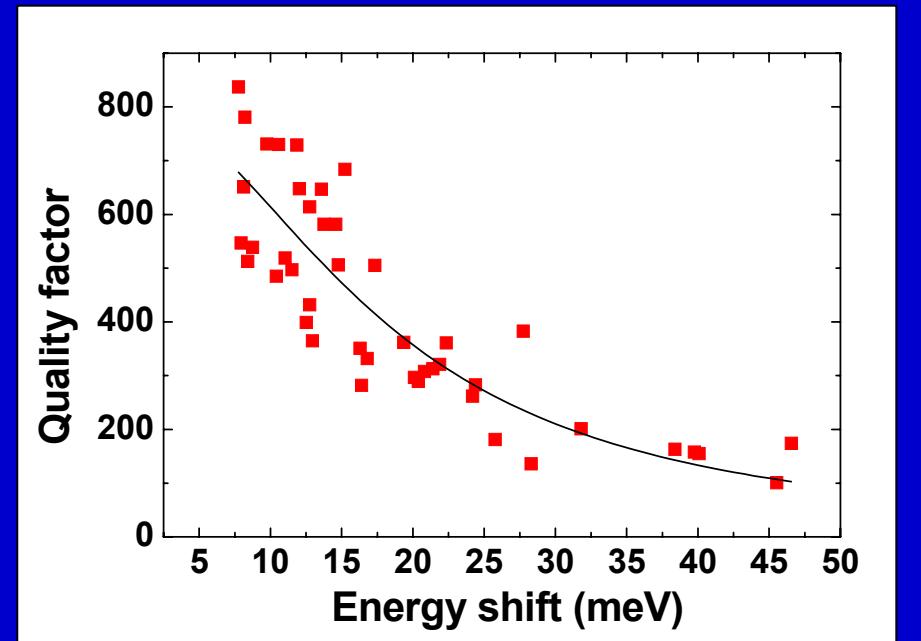
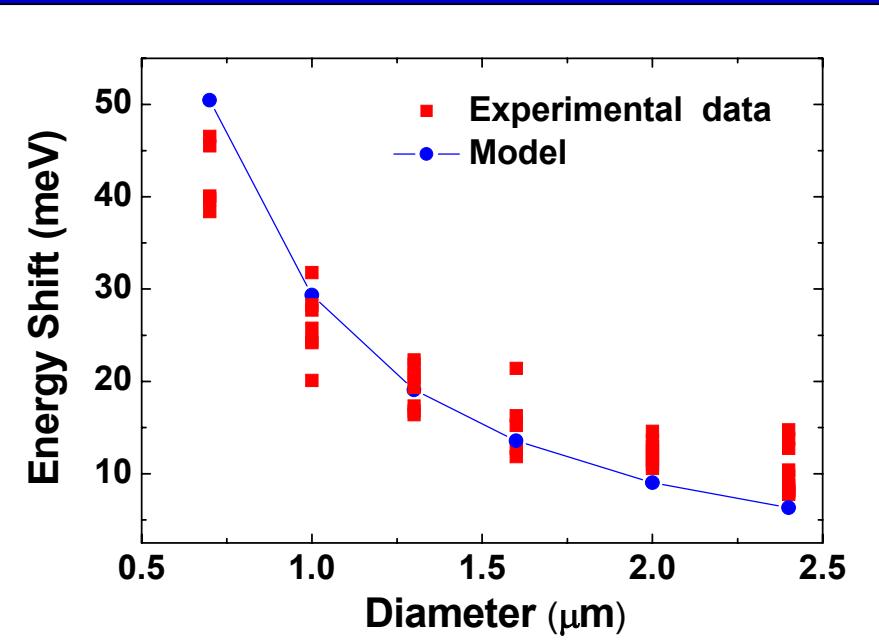
Design quality factor:  $Q=1000$   
Calculated Purcell effect for  $\Phi=300$  nm:

$$F_P = \frac{3}{4\pi^2} \frac{(\lambda/n)^3}{V_{cav}} Q \approx 40 \quad (\text{ Ideally!})$$

Spectroscopy of cavity modes under electrical pumping:

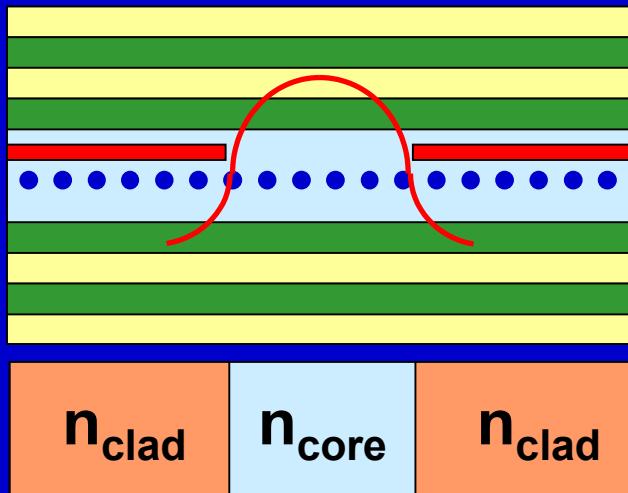


# 3D microcavity LED: Spectra



Zinoni et al., APL 2004

Effective index model:



Loss increases with increasing confinement

For  $F_p \gg 1$ : Need  $Q \approx 1000$  for  $\Phi < 1 \mu\text{m}$

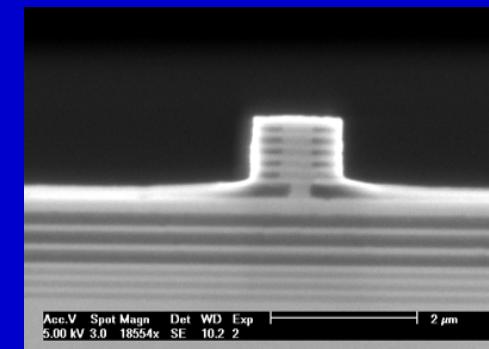
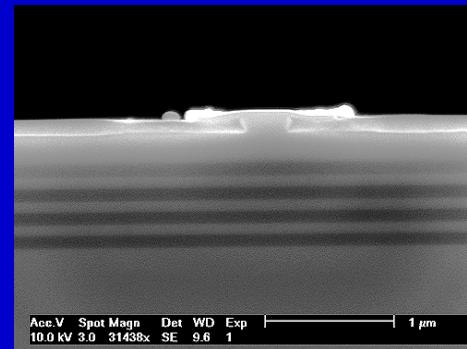
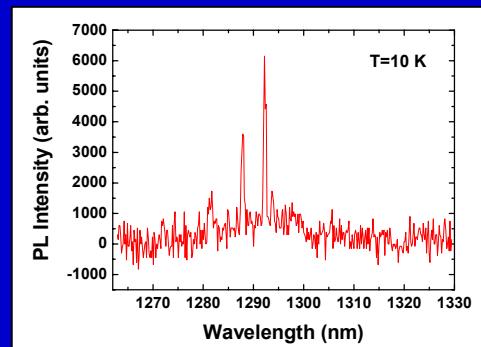
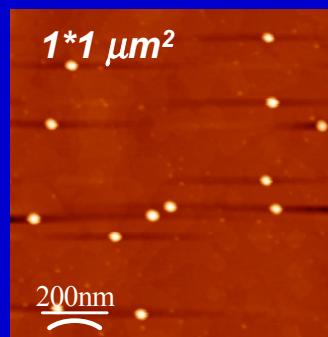
# Summary



- Low growth rate  $\Rightarrow$  sparse, long-wavelength QDs
- Single QD spectroscopy at  $1300\text{ nm}$
- Carrier injection in  $<300\text{ nm}$  with oxidized apertures
- Strong optical confinement in  $\approx\lambda^3$  volumes



Towards efficient single-QD LEDs



Andrea Fiore

